

Feedhorn-coupled MKIDs fabricated from TiN/Ti multilayer films



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- Gene Hilton
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- Jeff Van Lanen
- Chris McKenney
- Mike Vissers

- Chris Groppi
- Hamdi Mani
- Phil Mauskopf
- Matt Underhill

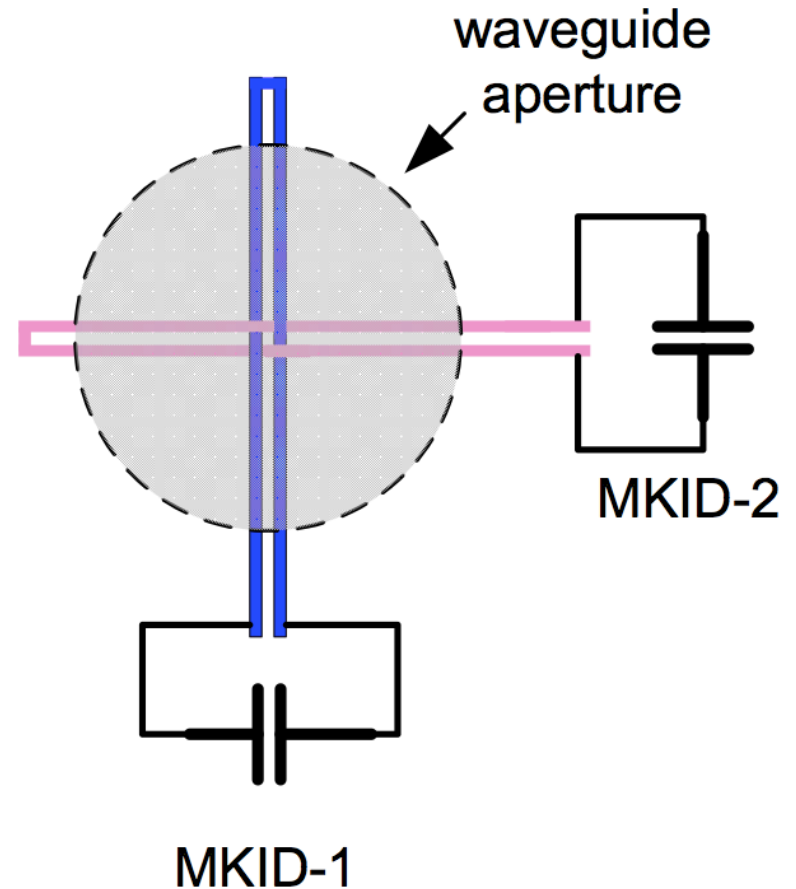
- Sherry Cho
- Kent Irwin
- Dale Li



- Mark Devlin
- Brad Dober
- Nicholas Galitzki

Project goals

- develop general purpose MKID technology that covers 0.075-1.4 THz
- technology includes
 - optical coupling
 - MKID detector arrays
 - wide-bandwidth amplifiers
- warm readout electronics



Application: BLAST-TNG

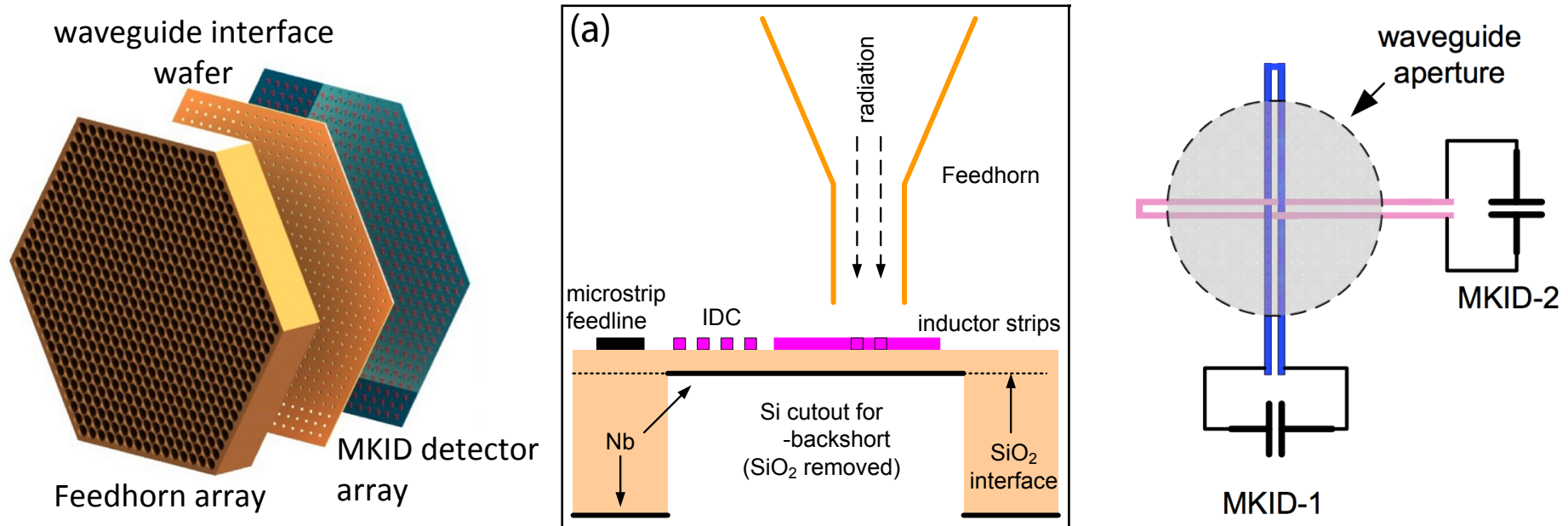
- **Motivation:** study role of magnetic fields in star formation
- **Experimental approach:** observations of polarized dust emission at sub-mm wavelengths from a balloon using arrays of polarization sensitive MKIDs at 250, 350 and 500 micron

BLAST: Balloon-Borne Large Aperture Submillimeter Telescope



PI: Mark Devlin (UPENN)

Feedhorn-coupled, dual-polarization sensitive MKIDs

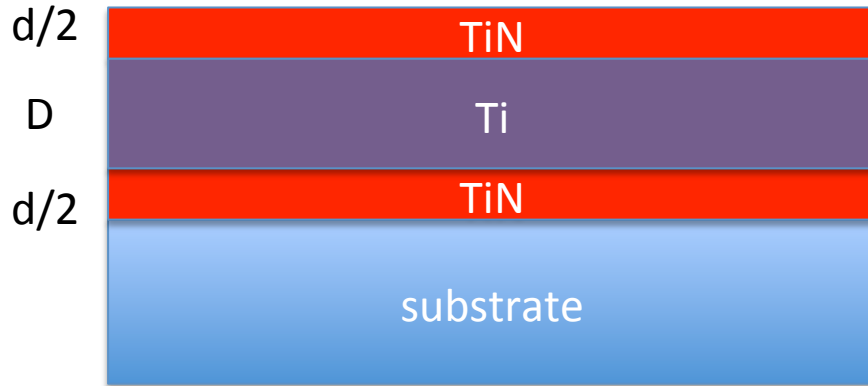


Hubmayr et al. *IEEE Trans Appl Sup* 2013

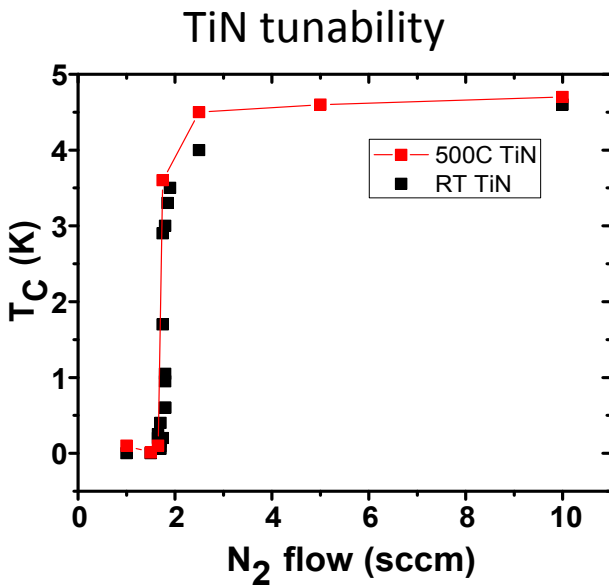
- feedhorn-coupled
- TiN/Ti multilayer superconducting material
- lumped element kinetic inductance detectors

- scalable to large detector-count cameras
- dual-polarization sensitivity
- beam properties defined by feedhorns
- once designed, fast to produce
- low number of focal plane interconnects

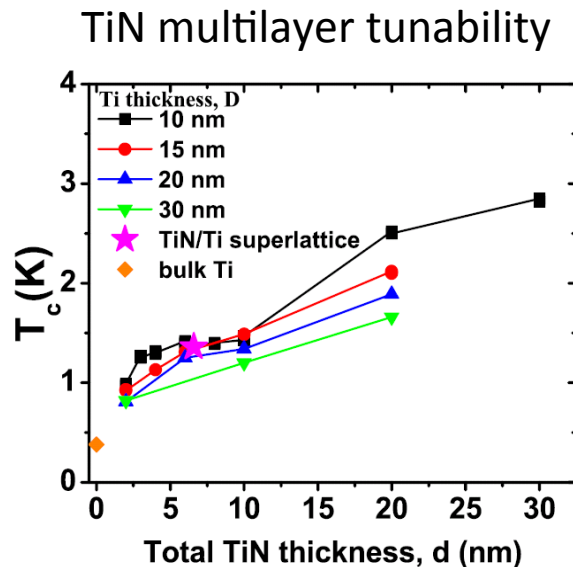
TiN multilayers



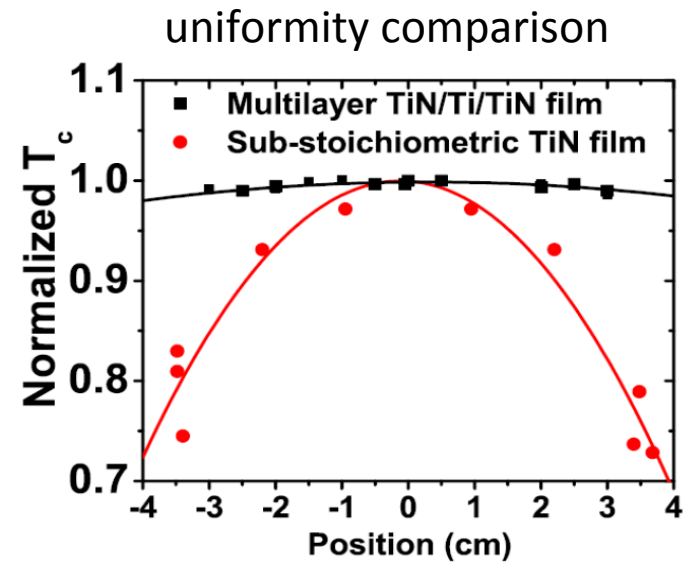
- based on TiN work from Caltech/JPL
- high spatial T_c uniformity increases array yield
- adjustable T_c and ρ enable optimization for detection over broad wavelength range and loading conditions



(a)



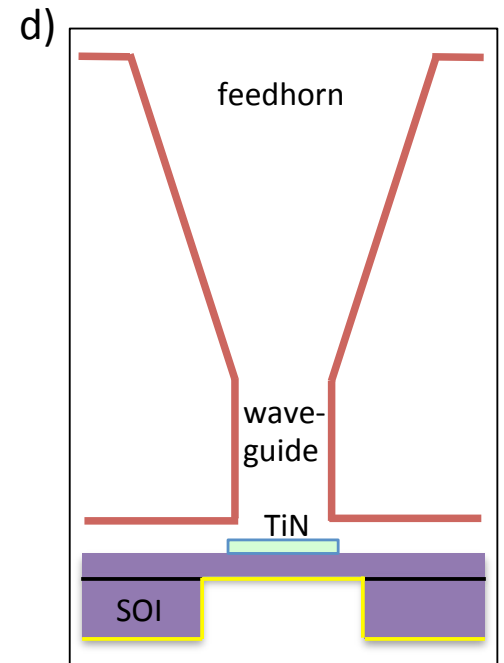
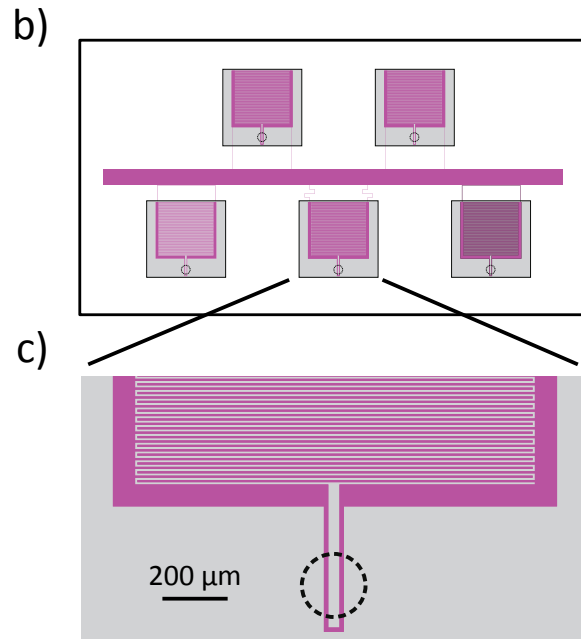
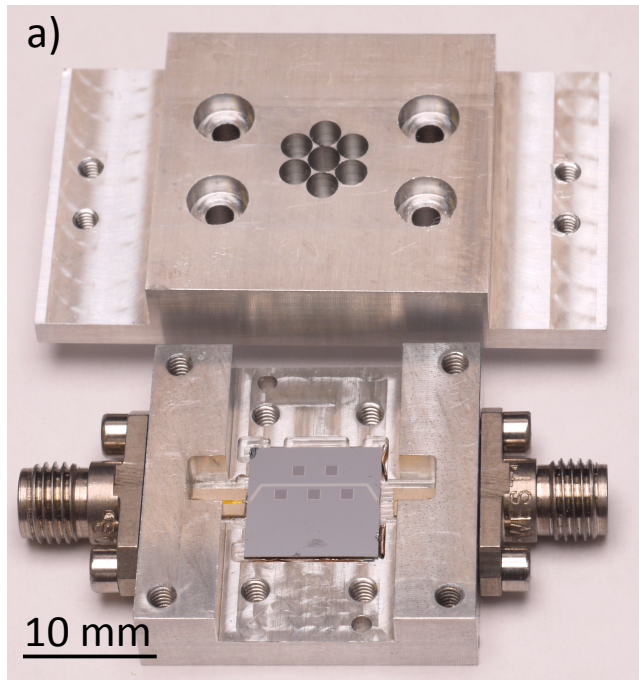
(b)



(c)

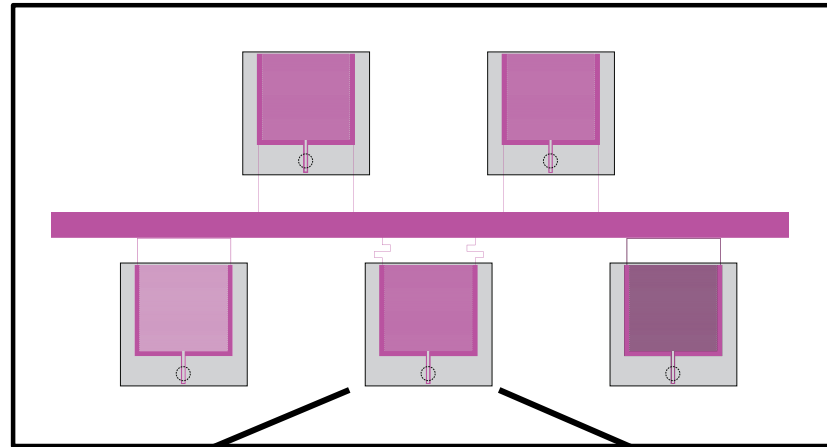
Vissers et al APL 2013

lab-based sensitivity experiment



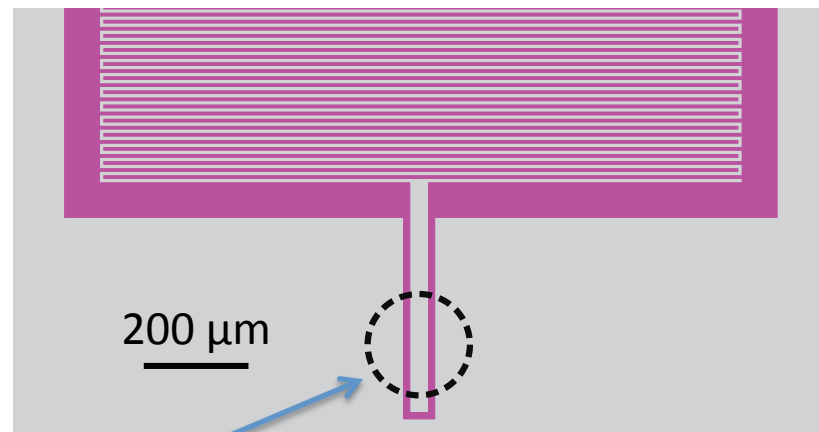
device design

microstrip feedline
coupled



shaded region is
backside etched to
create 18 μm thick
Si backshort

$f \sim 1 \text{ GHz}$

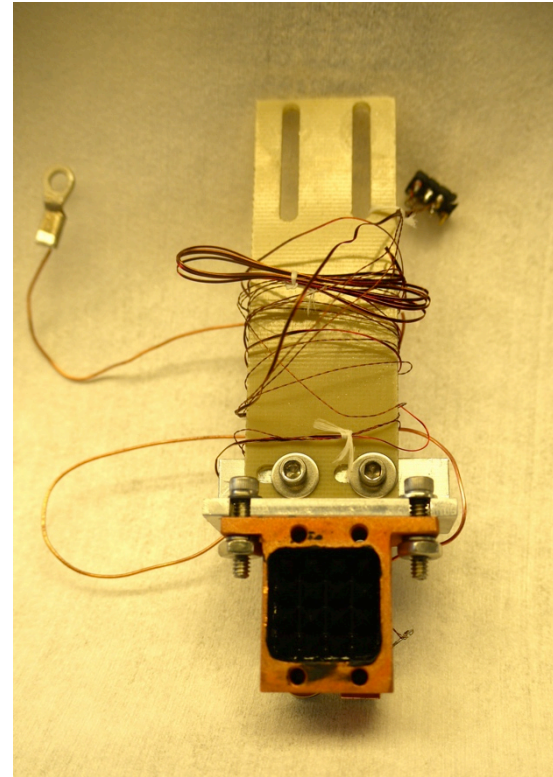
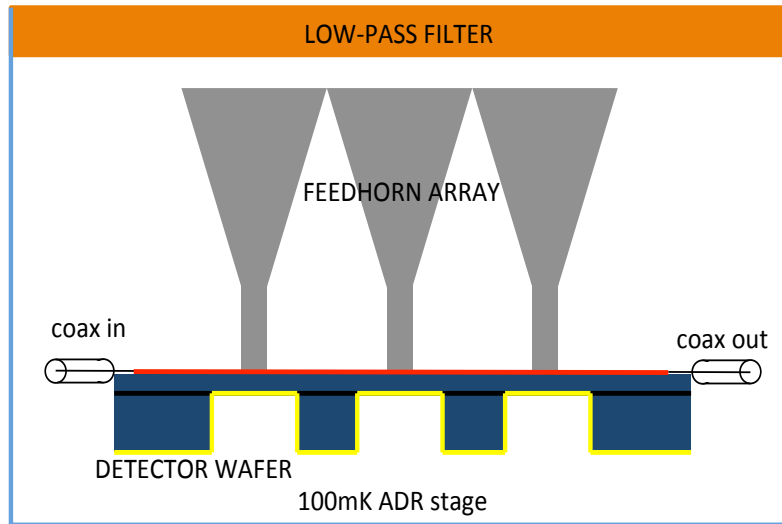
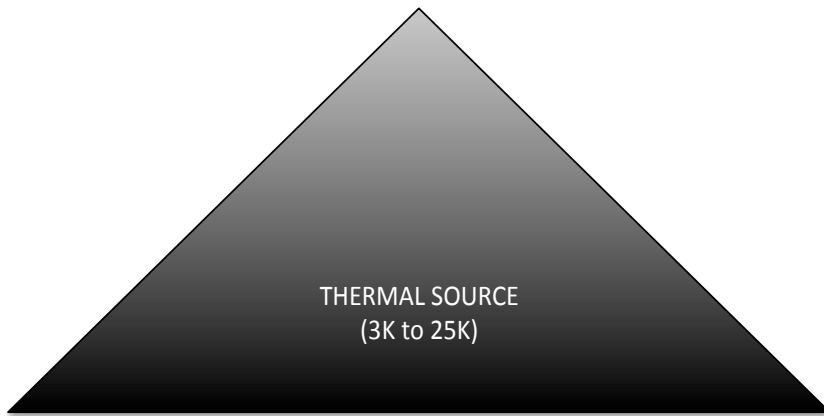


waveguide diameter

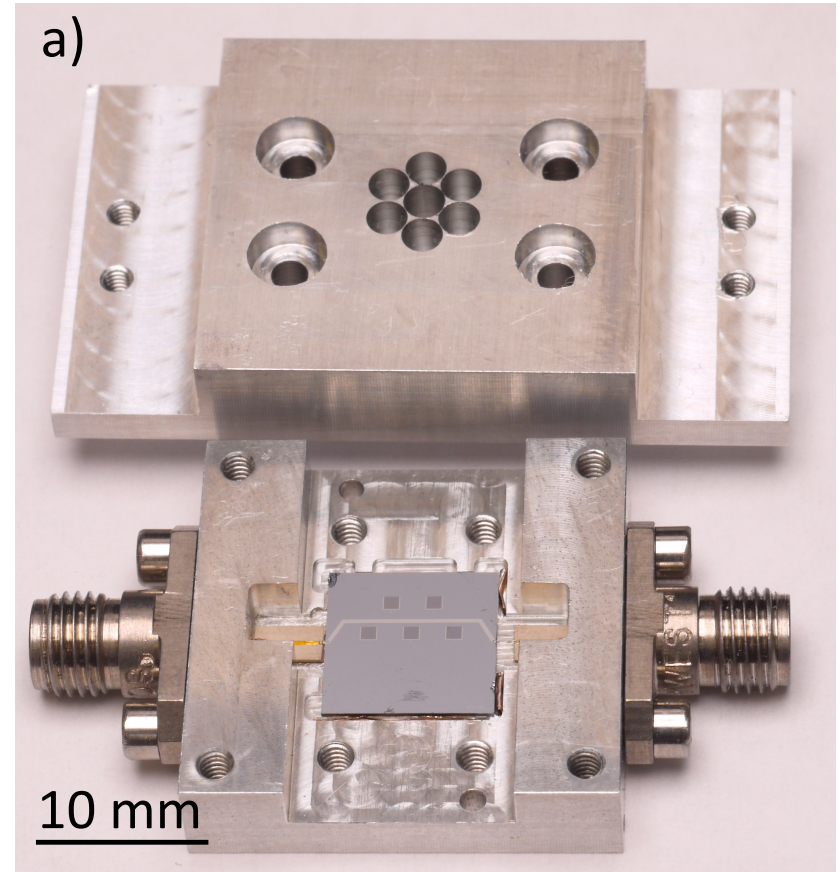
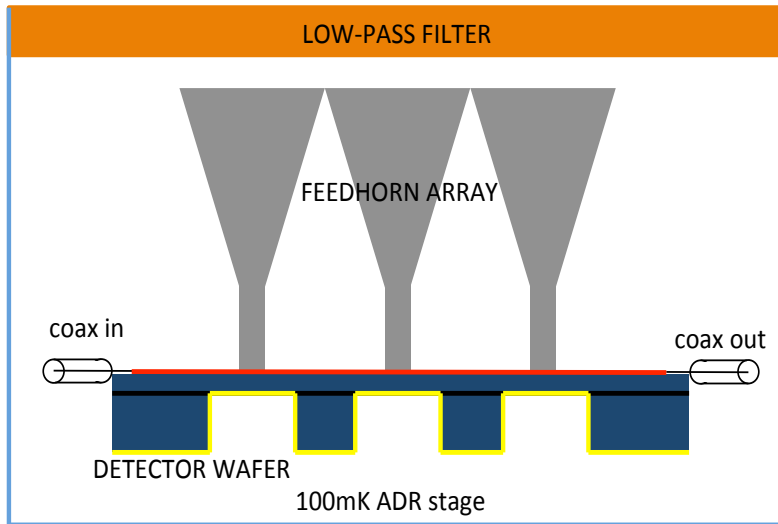
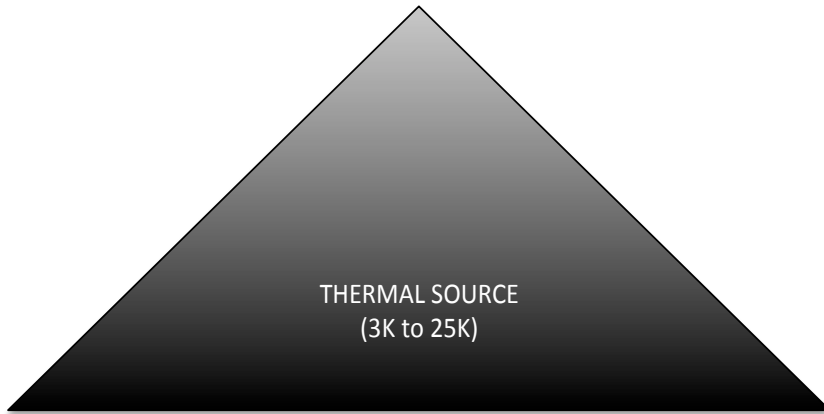
IDC capacitor:
5 μm finger/gap

1-turn inductor:
10 μm wide
Absorber volume =
85 μm^3

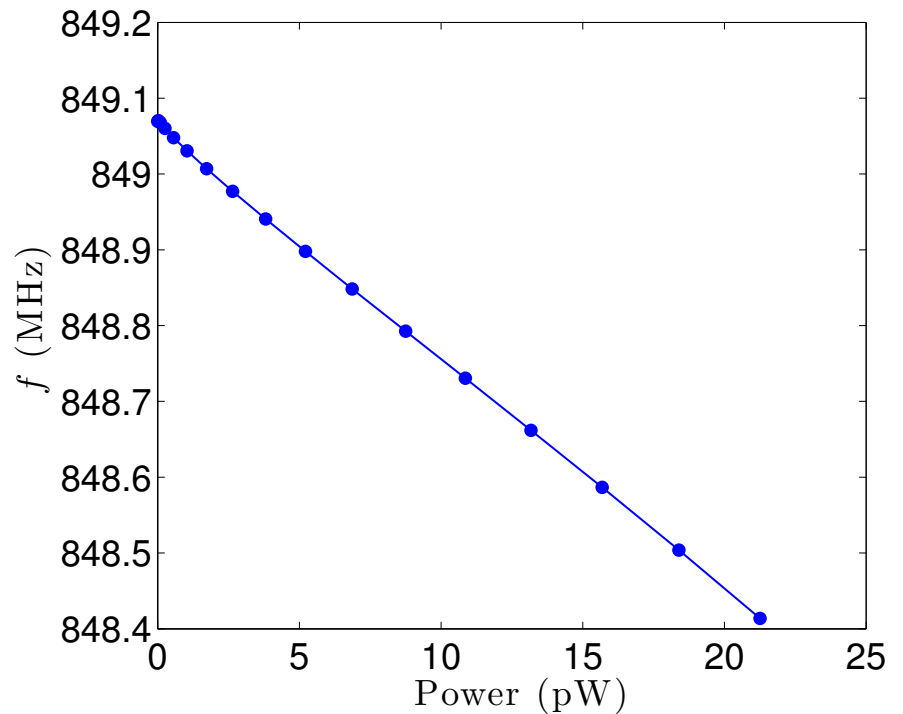
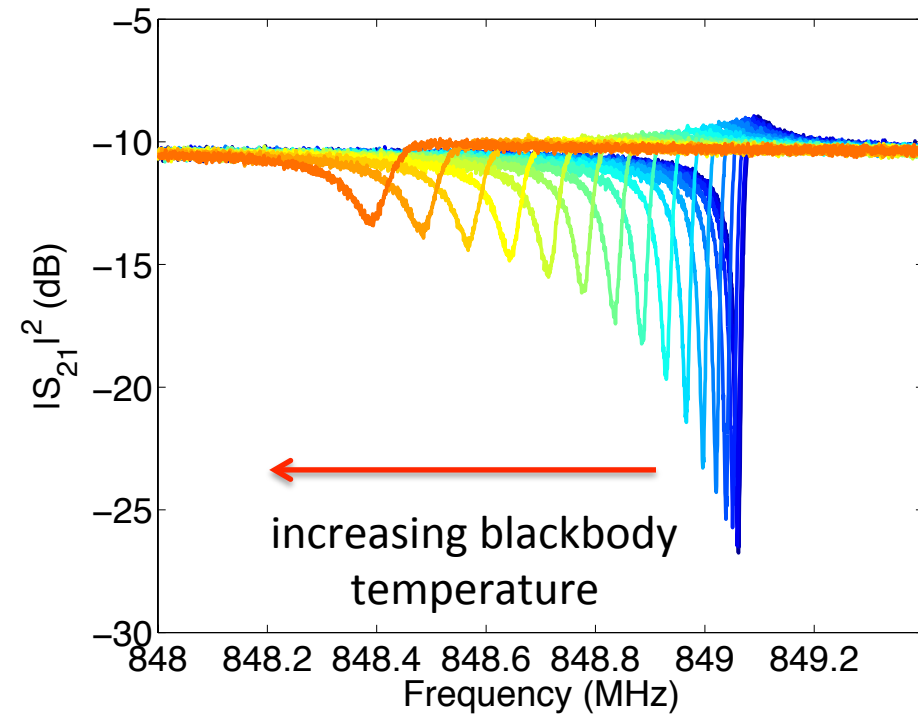
thermal load experimental setup



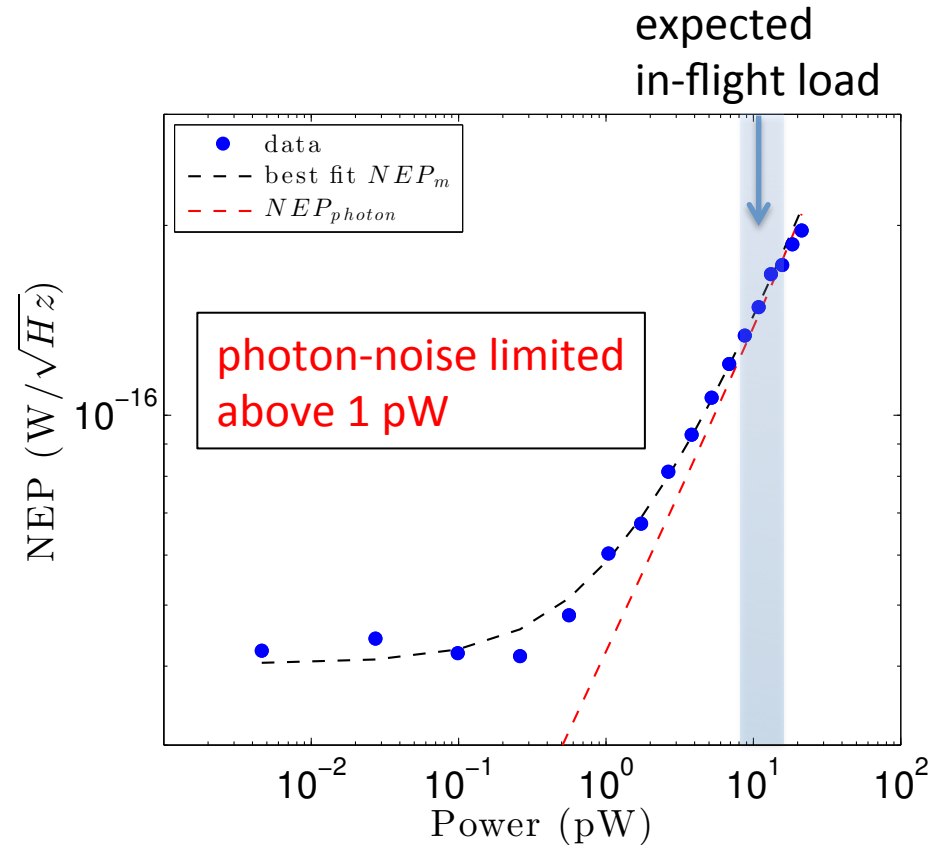
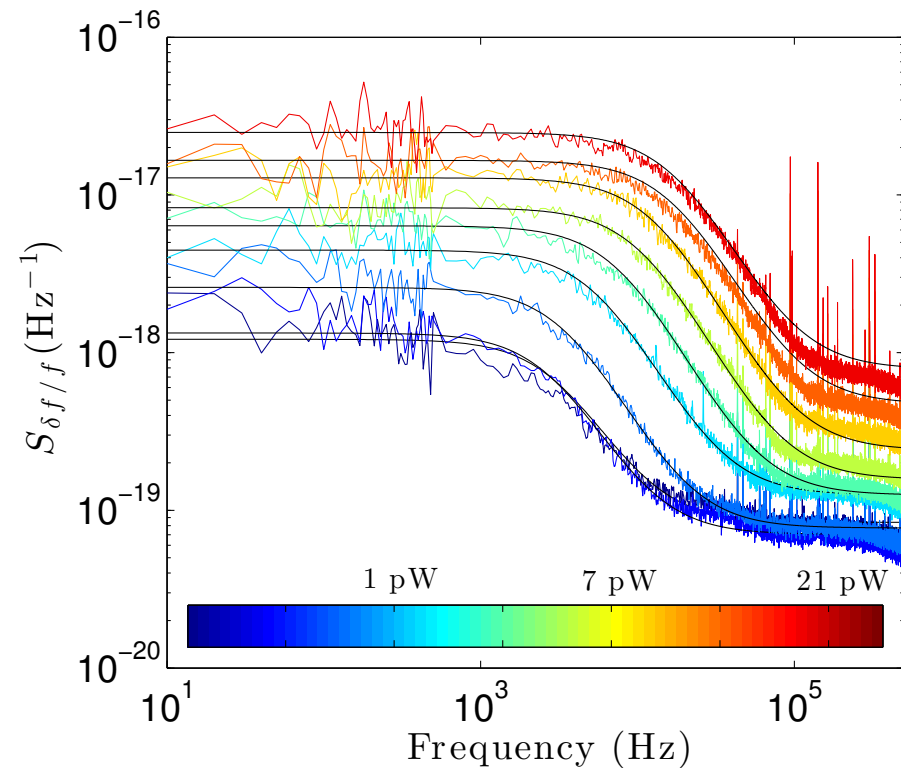
thermal load experimental setup



device response



photon-noise limited



Hubmayr et al. APL **106**, 7 (2015)

Dual-polarization sensitive MKID demonstration

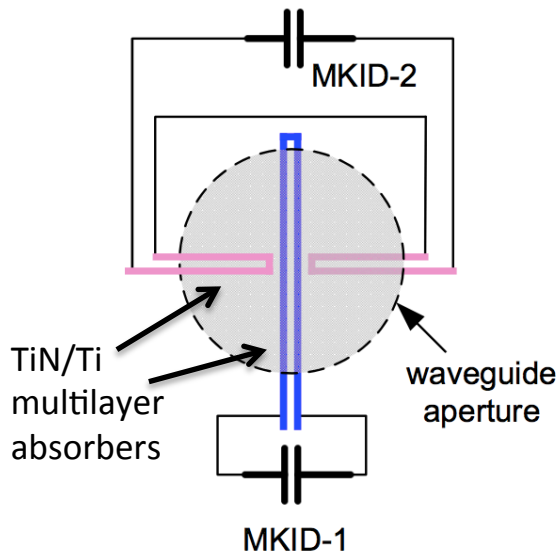
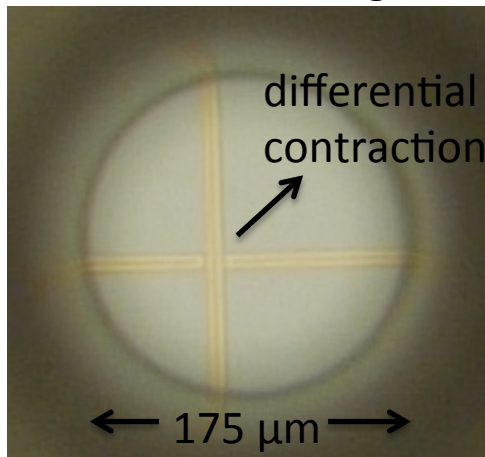
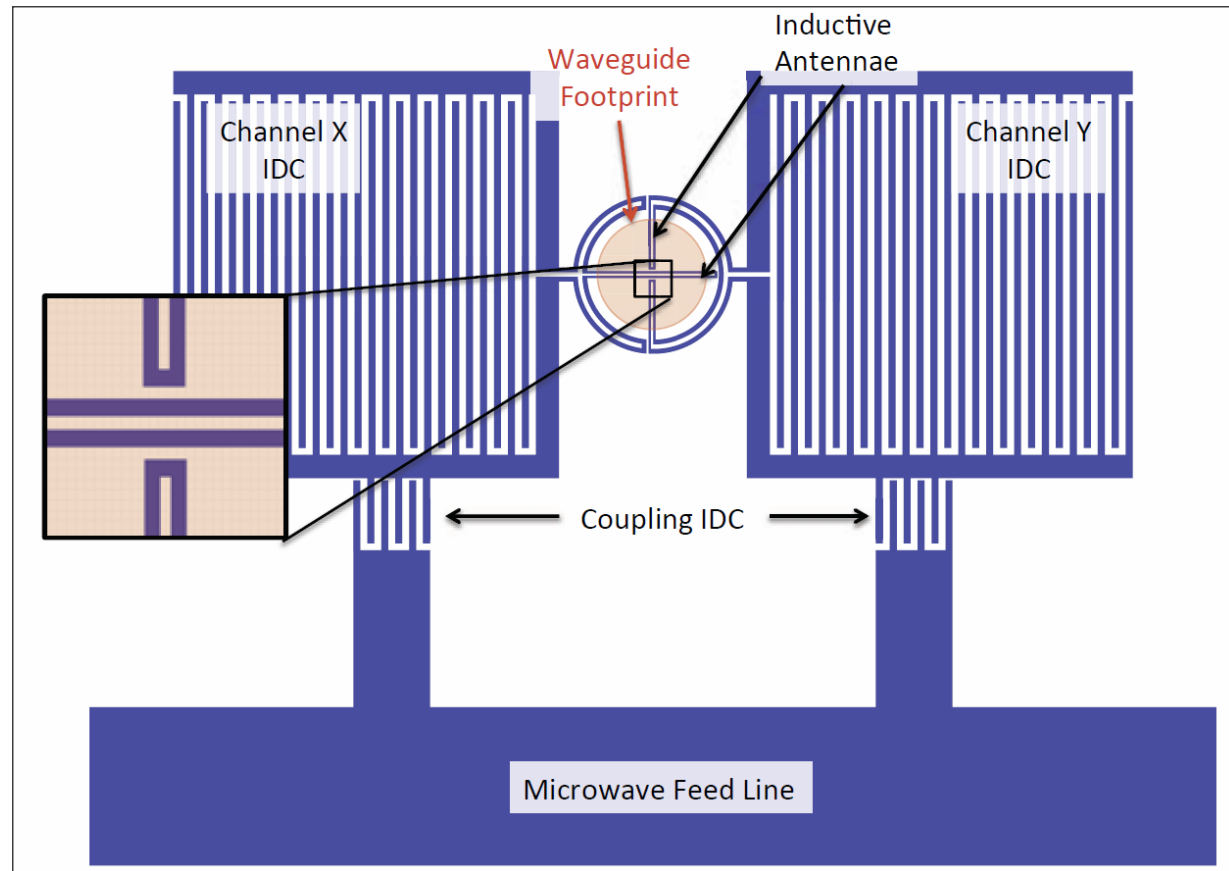


Photo down waveguide



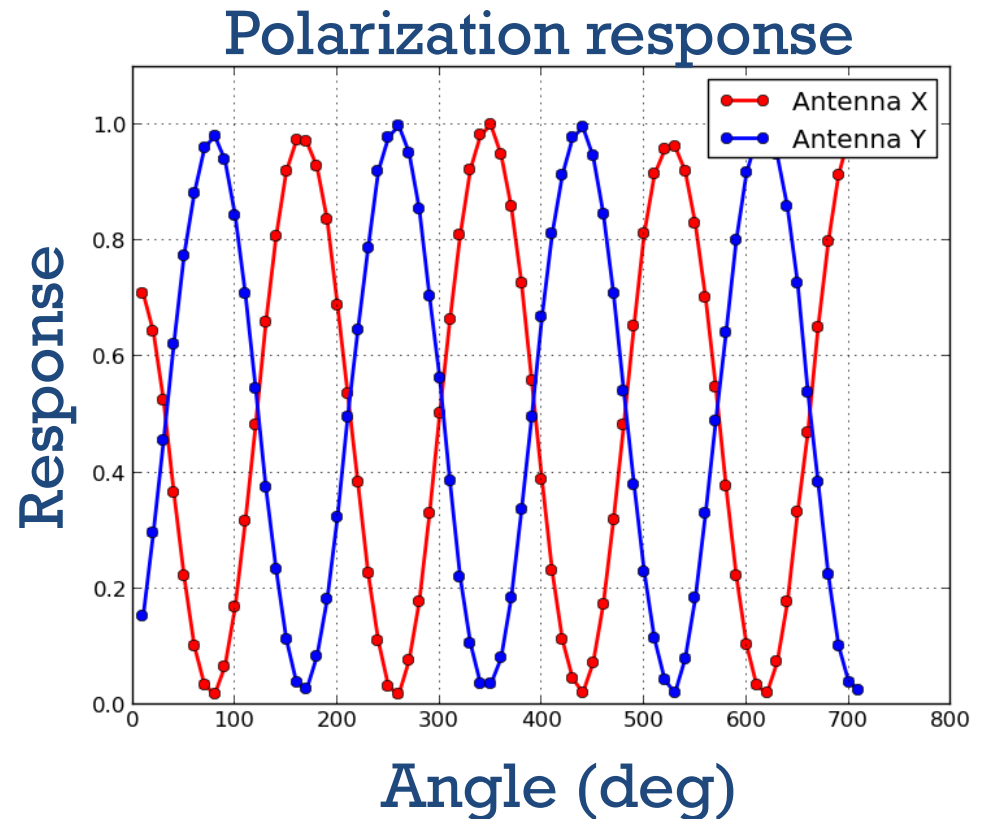
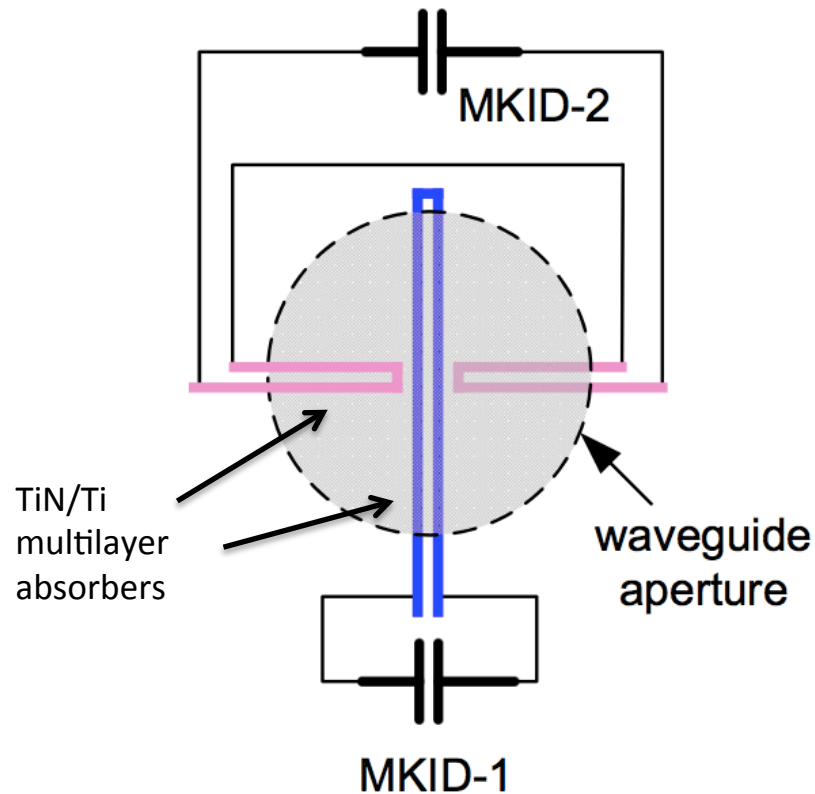
pixel design
single metal layer with no cross-overs



Dober et al. submitted to *JLTP*

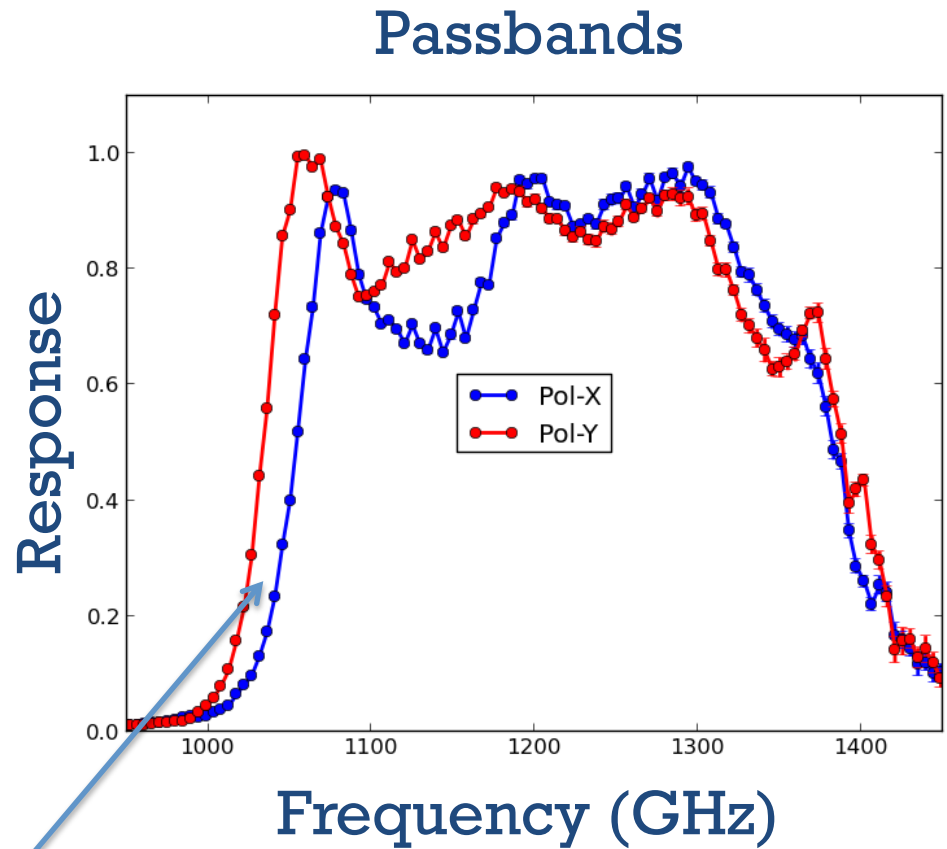
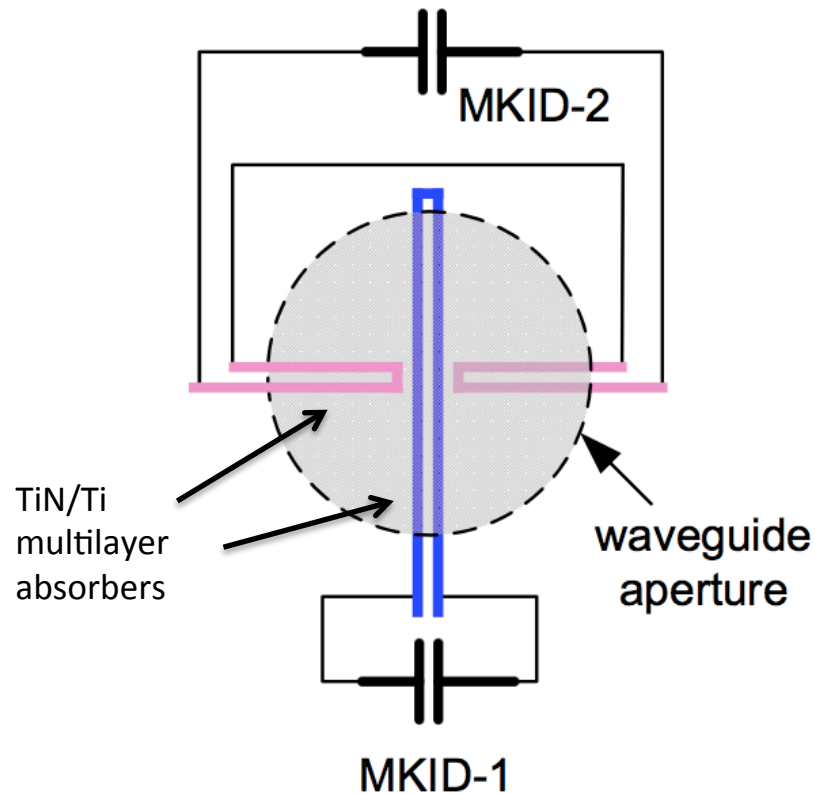
Dual-polarization sensitive MKID demonstration

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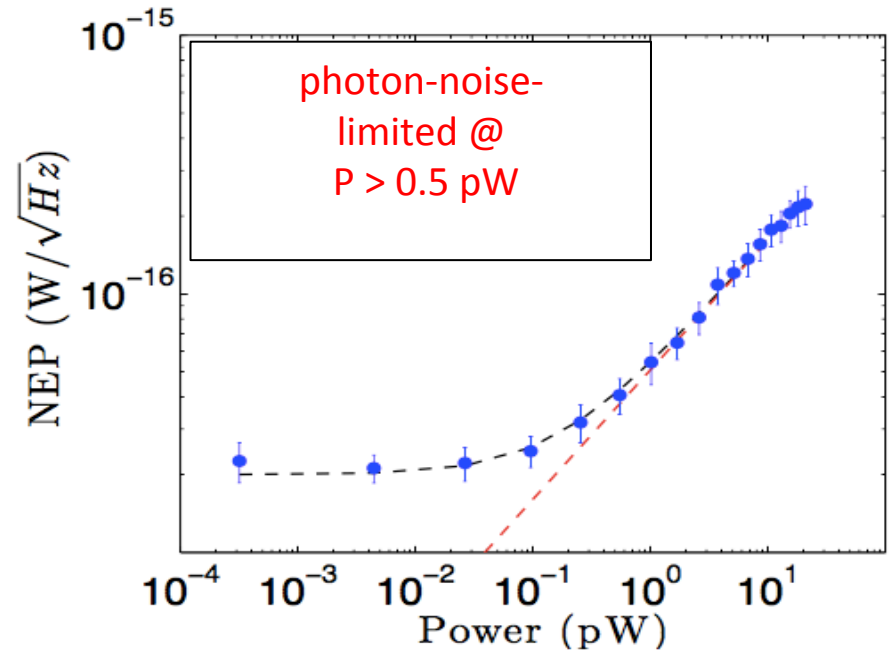
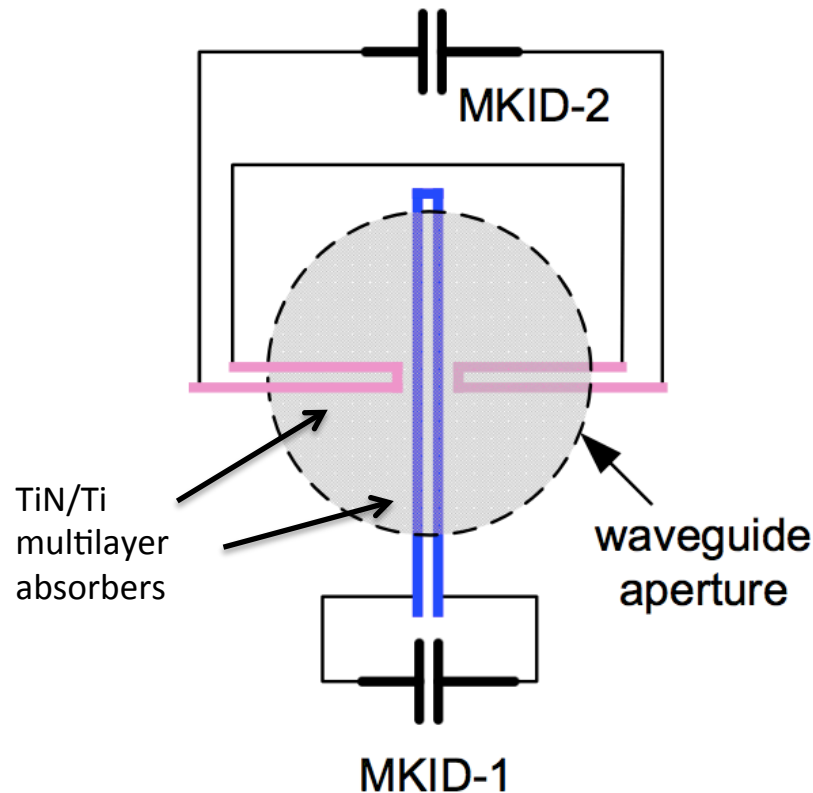
Dober et al. submitted to *JLTP*



likely due to oval-shape
waveguide from direct machining

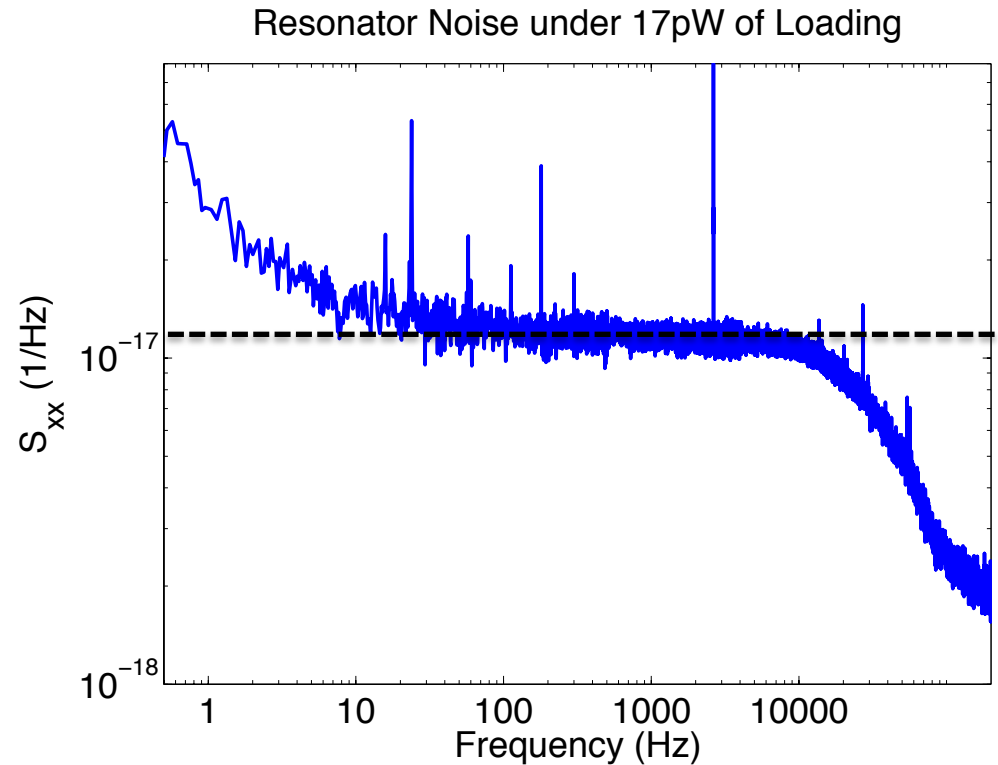
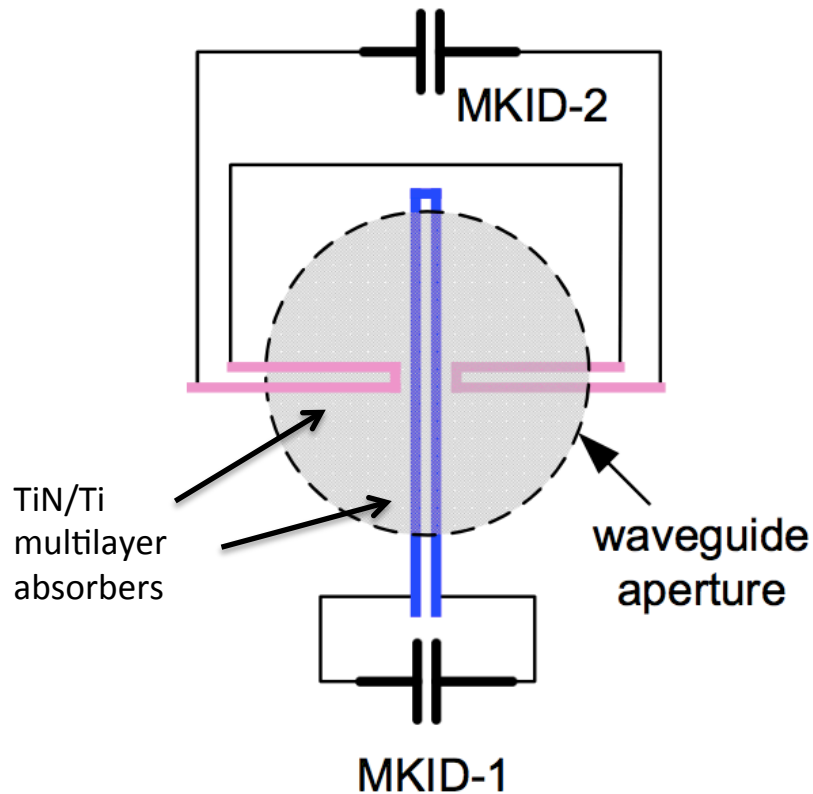
Dual-polarization sensitive MKID demonstration

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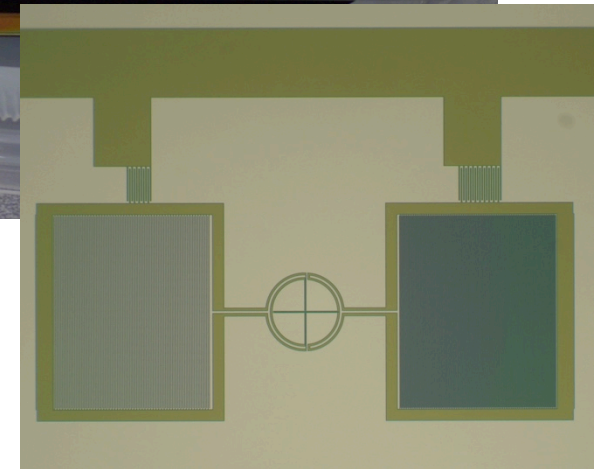
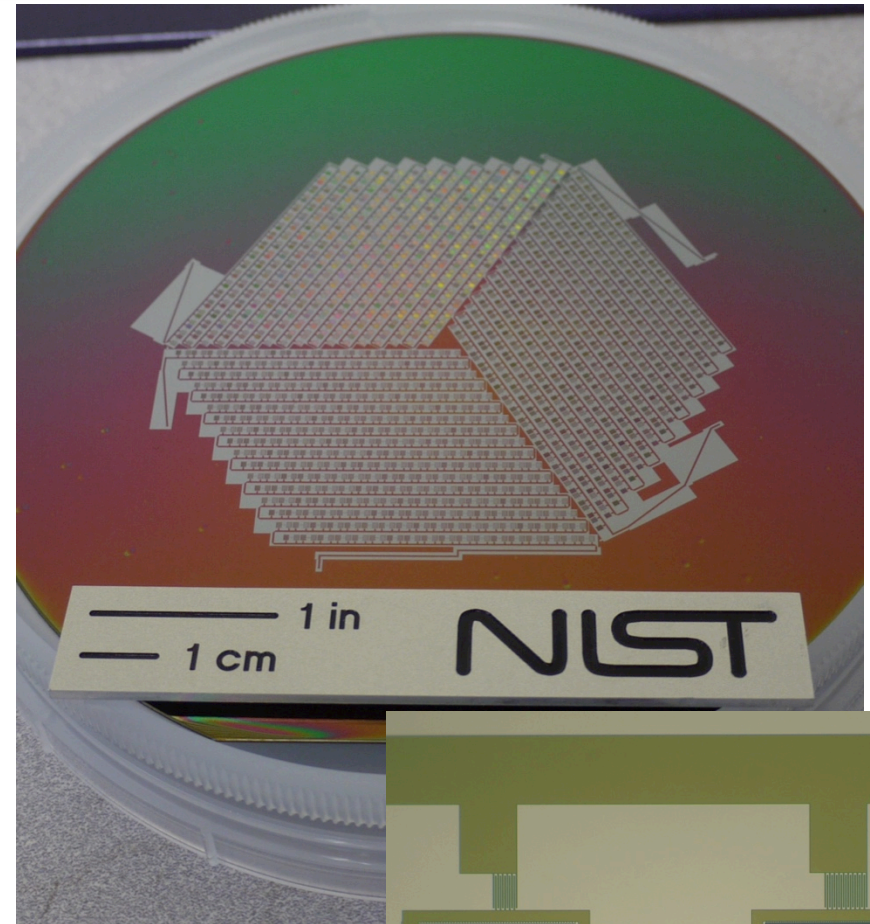
$\eta_{\text{opt}} = 75\%$ relative to 1-1.4THz top hat band
This matches HFSS coupling simulations

Low Frequency Noise

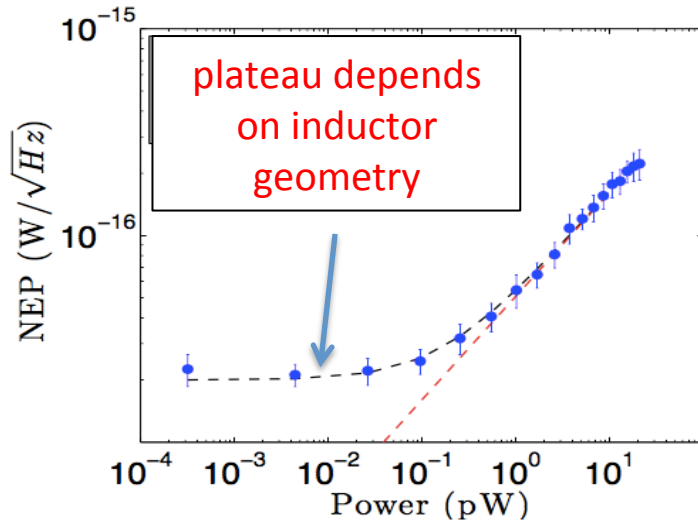


Array fabrication

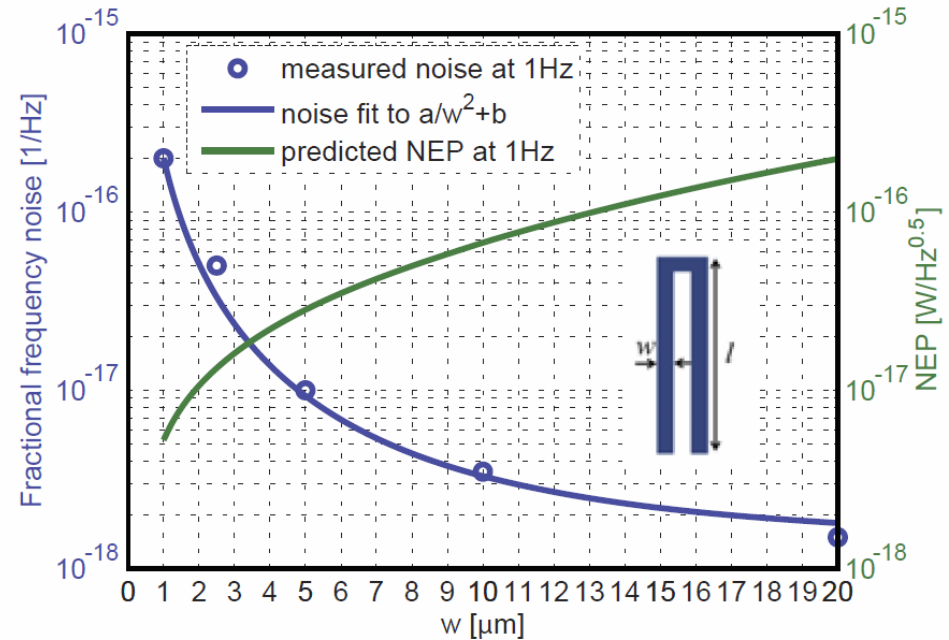
- BLAST-TNG 250um array
- 918 dual-polarization pixels
- 1836 MKIDs
- three microwave feedlines
- ~600 channels per feedline driven by total ADC bandwidth of readout
- all stepper-defined lithography



Detector noise scaling



- NEP proportional to inductor width
- consequence of observed inductor noise + linear responsivity



to make a more sensitive detector, shrink the inductor width

summary

achievements

- BLIP sensitivity at 250um
- dual-pol demo at 250um
- empirical noise model developed
- array fabrication process

next steps

- Balloon-borne implementation at 250, 350 and 500 micron on BLAST-TNG
- demonstrate 90 GHz dual-pol direct absorber approach
- develop OMT-coupled MKIDs

